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208418US-10944-8663-2 PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF: :

TOMOKO OHTSUKI ET AL : ATTN: APPLICATION DIVISION

SERIAL NO: NEW U.S. PCT APPLN :  
(Based on PCT/JP00/05875)

FILED: HEREWITH : EXAMINER:

FOR: LIGHT SOURCE UNIT AND :  
WAVELENGTH STABILIZING  
CONTROL METHOD, EXPOSURE  
APPARATUS AND EXPOSURE  
METHOD, METHOD OF MAKING  
EXPOSURE APPARATUS, AND  
DEVICE MANUFACTURING  
METHOD AND DEVICE

PRELIMINARY AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS  
WASHINGTON, D.C. 20231

SIR:

Prior to a first examination on the merits, please amend the above-identified  
application as follows:

IN THE SPECIFICATION

Page 32, lines 5-16, please delete the paragraph and replace it with the following

paragraph:

With the fourth light source unit according to the present invention, the temperature  
dependence data may further include data on temperature dependence of the center  
wavelength of the laser beam oscillated from the laser light source, and the first control unit  
may perform wavelength control of the laser light source together, when performing the